Accepted Manuscript

Title: Effect of thermal annealing on structural, optical and electrical properties of transparent Nb₂O₅ thin films

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PII: DOI: Reference: S2352-4928(17)30103-4 http://dx.doi.org/10.1016/j.mtcomm.2017.09.004 MTCOMM 203

To appear in:

Received date:	18-5-2017
Revised date:	12-9-2017
Accepted date:	20-9-2017

Please cite this article A.A.Atta, M.M.El-Nahass, A.M.Hassanien, as: Khaled M.Elsabawy, M.M.Abd El-Raheem, A.Alhuthali, Sultan E.Alomariy, M.S.Algamdi, Effect of thermal annealing on structural, optical and properties of transparent electrical Nb2O5 thin films, Materials Today Communicationshttp://dx.doi.org/10.1016/j.mtcomm.2017.09.004

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ACCEPTED MANUSCRIPT

Effect of thermal annealing on structural, optical and electrical properties of transparent Nb₂O₅ thin films

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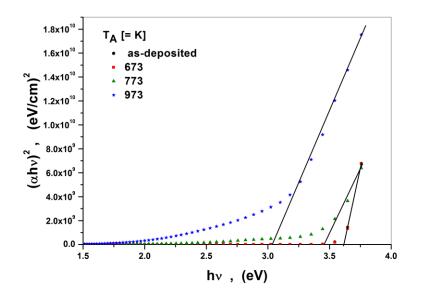
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Graphical Abstract



Variation of (ahv)² as a function of photon energy (h v) for the as-deposited and annealed Nb₂O₅ thin films

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